

Design of a two stage amplifier using ACM model

ECEN 607(ESS)

Courtesy of
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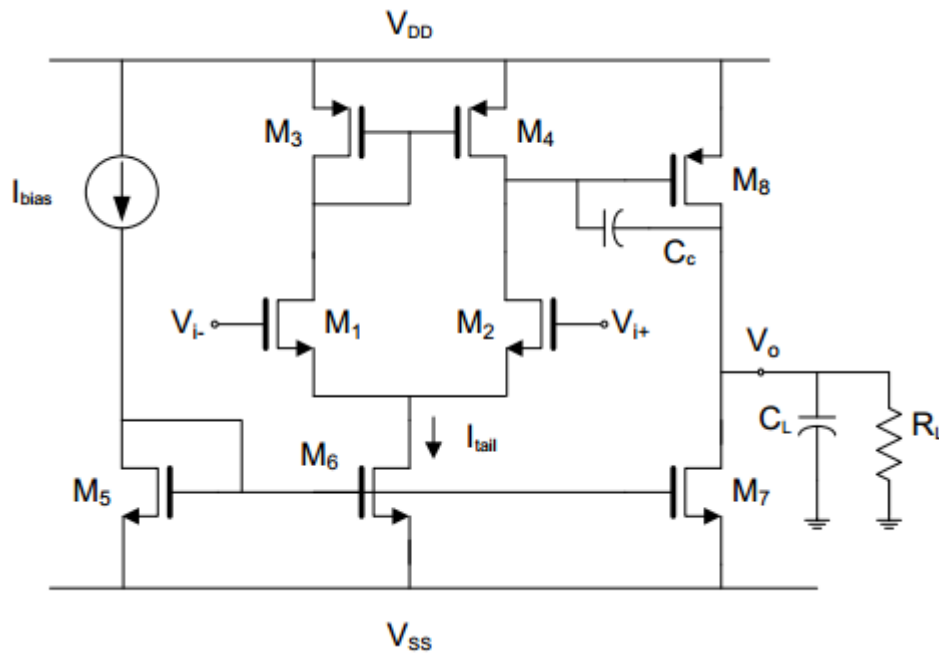
Contents

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Why ACM model?

- Powerful tool for the simulation of MOS transistors
- Simple, precise equations to extract physical parameters
- Parameters describe effects particular to newer small channel technologies
- Valid for the efficient design of analog circuits
- Better match between simulations and actual circuit performance

Amplifier Specifications



Specifications	Value
A_{vo} (DC gain)	> 50 dB
GBW	> 20 MHz
PM (Phase Margin)	> 50°
SR (Slew Rate)	> 1.7 V/us
C_L	50pF
C_{in}	<0.8 pF
In band noise (DC-10MHz)	<10 μ V
Supply	1V

Amplifier Specifications

- Boundary conditions

- $\frac{gm_1}{C_c} = GBW > 20 \text{ MHz} \dots\dots\dots(1)$

- $\frac{I_{tail}}{C_c} = \text{Slew Rate} > \frac{1.7V}{\mu s} \dots\dots\dots(2)$

- $V_{eq_{in}}^2 \cong \frac{16KT}{3gm_1} \left[1 + \frac{gm_8}{gm_1} \right] \dots\dots\dots(3)$

- $PM = 180 - \tan^{-1} \left[\frac{GBW}{w_{p1}} \right] - \tan^{-1} \left[\frac{GBW}{w_{p2}} \right] - \tan^{-1} \left[\frac{GBW}{w_{z1}} \right] \dots\dots(4)$

- Cancel zero by using $R_z = \frac{1}{gm_8}$

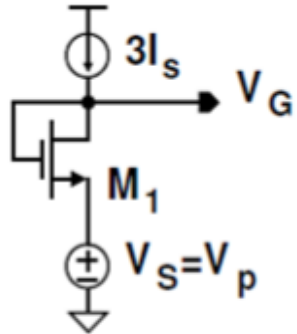
- Assume phase contribution of w_{p1} is about $\frac{\pi}{2}$ and $f_{p2} > 80\text{MHz}$ (from (4) and amplifier specifications for phase margin $> 60^\circ$)

- $\left[\frac{gm_8}{C_L} \right] = f_{p2} \Rightarrow gm_8 > 1\text{mS}$

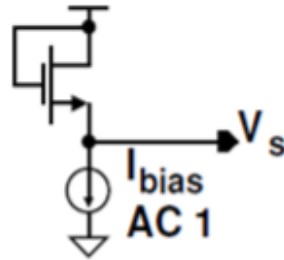
- From (1) $gm_1 > 240\mu\text{S}$

- From (3), $I_{tail} > 8.5\mu\text{A}$

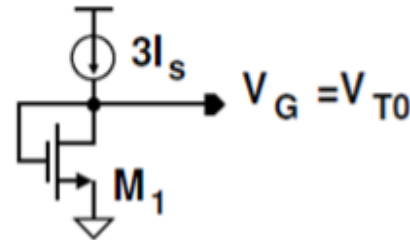
Parameter extraction for design(65nm)



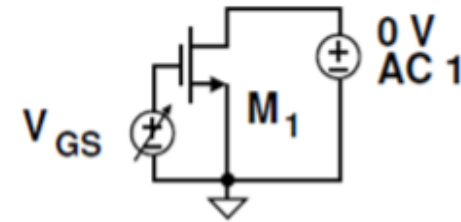
extraction of γ



I_s extraction



V_{to} extraction



extraction of μ

- Using [1], the following parameters can be extracted

Parameter	NMOS(65nm)	PMOS(65nm)
I_s/nA	333.8	46.8
V_{th0}/V	0.4238	-0.349
$\Gamma/mV^{1/2}$	0.207	0.293
Σ/m^2	21.12f	5.679p
PCLM	0.0409	0.159
$\mu/cm^2/Vs$	267.3	70.4
θ/V^{-1}	0.32	0.1995

Amplifier dimensions calculations

- Choose $i_f = 0.5$, assume $g_{m1,8} = 1.5mS$
- Check intrinsic cutoff frequency of transistor at $i_f = 0.5$
- $f_T = \frac{\mu\phi_t}{2\pi L^2} (2\sqrt{1 + i_f} - 1) = 51.5GHz \gg 20MHz$ —(5)
- $I_d = gm * n * \phi_t \frac{1 + \sqrt{1 + i_f}}{2} \cong 50\mu A$ —(6)
- $\frac{W}{L} = \frac{gm}{\mu C_{ox} \phi_t (-1 + \sqrt{1 + i_f})}$ —(7)
- $\frac{W}{L_N} (65nm) = 336 \frac{W}{L_P} (65nm) = 1276$
- $\frac{V_{DSAT}}{\phi_t} \cong (\sqrt{1 + i_f} - 1) + 4 \Rightarrow V_{DSAT} \cong 0.1V$

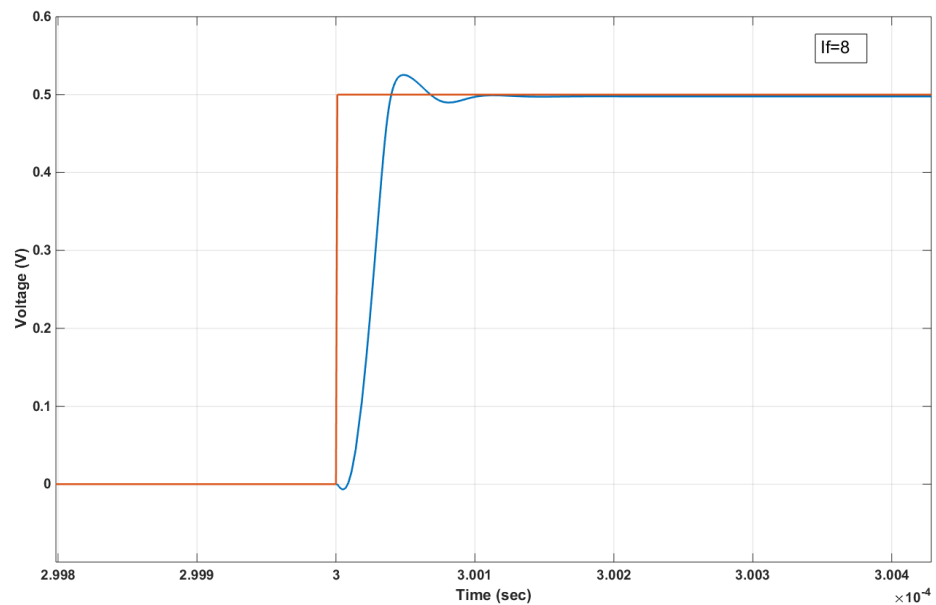
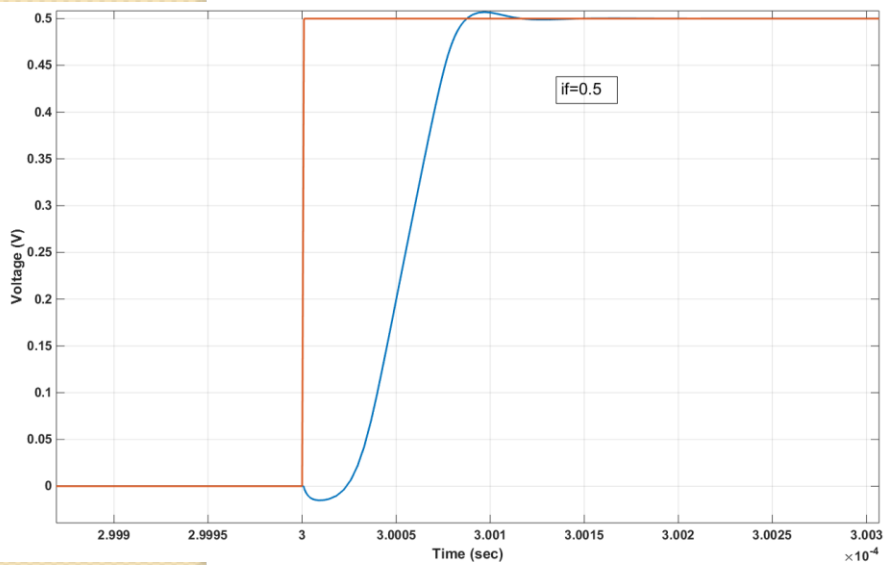
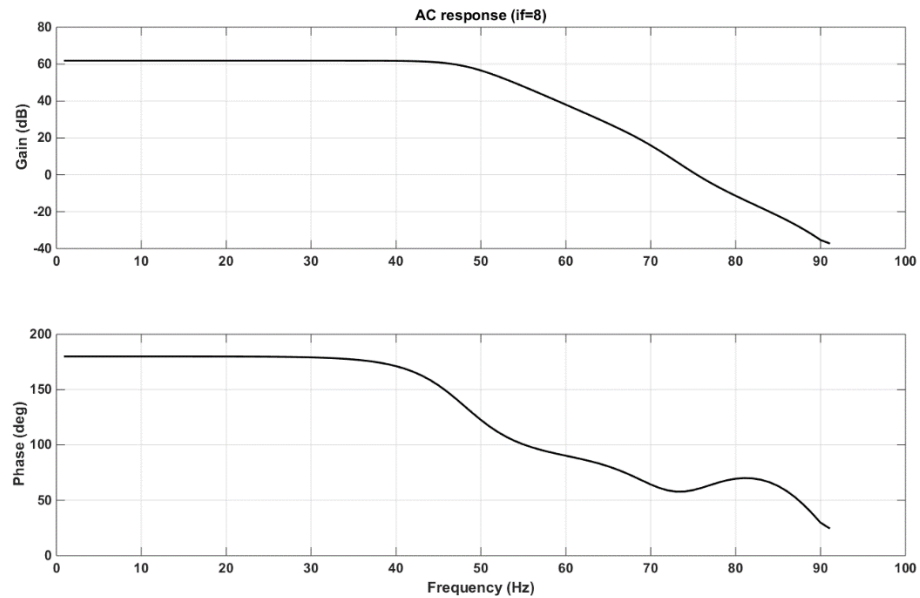
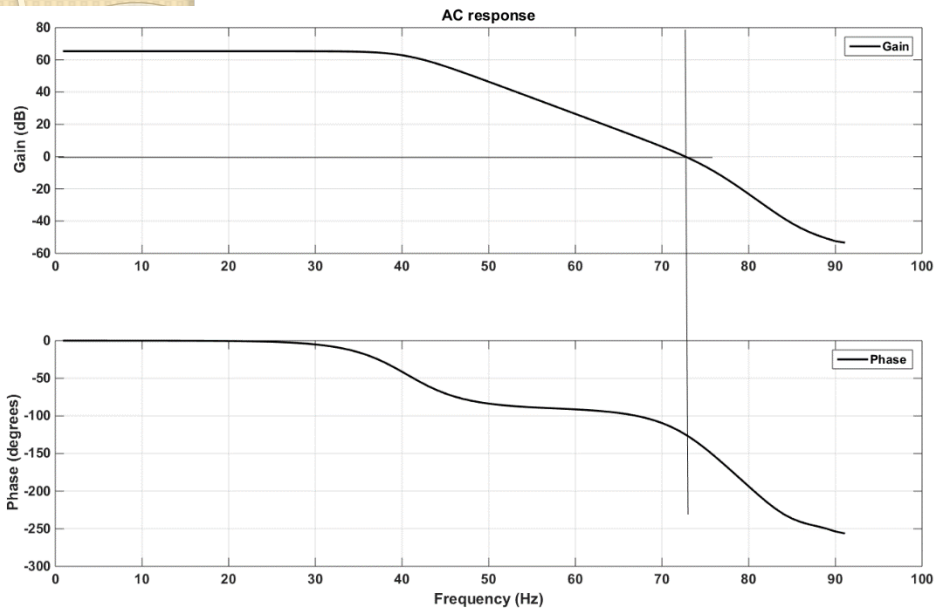
Amplifier design ($i_f=8$)

- Choose $i_f = 8$, choose $g_{m1,8} = 1.5mS$
- Check intrinsic cutoff frequency of transistor at $i_f = 8$ using (5)
- $f_T = 130GHz \gg 20MHz$
- $I_d \cong 93\mu A$
- $\frac{W}{L_N} (65nm) = 4$; $\frac{W}{L_P} (65nm) = 16$
- $V_{DSAT} \cong 0.208V$

Amplifier design recap

- First extract transistor parameters using ACM model and test benches
- First check if selected inversion level is adequate for your design, this is done by calculating the f_t of transistor, $f_t \gg 3 \times \text{GBW}$ (5)
- Use extracted parameters to calculate required transconductances, saturation voltage, dimensions based on specifications given as a first trial point
- Bias your circuit properly and perform your simulations
- Calculated values of M1, M2, M8 kept the same producing relative same gm at selected currents when ACM model is used (1)-(6).
- Reevaluate operational points to obtain required specifications

Example of results



Results

Parameter	$I_f=0.5$	$I_f=8$
Gain (dB)	65	61
Phase margin (deg)	50	60
Power dissipation (μW)	409	558
Settling time (nsec)	180	130
PSRR (dB)	66.3	62.4
Slew rate ($\text{V}/\mu\text{sec}$)	8.4	17.3
Area estimation ($\mu^2\text{m}^2$)	2400	100

- Smaller inversion level, larger area, slower response, lower power consumption
- Moderated inversion level, smaller area, larger power consumption, faster response

Conclusions

- ACM model effective in calculation of design parameters
- Very good first approximation
- Not region of operation specific